

# Transmission electron microscope measurement of the hydroxyapatite layers coated by droplets eliminated type pulsed-laser deposition scheme

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The high-crystalline hydroxyapatite layer was coated by a droplet-eliminated pulsed-laser deposition scheme on zirconia substrates [1]. Raman spectroscopy measurement showed that the coating layer changed drastically from amorphous to crystalline phase at annealing temperature  $T_a = 360$  °C. Moreover, narrowing and spectral upshift of the Raman spectral line over the threshold indicated the increase of the crystallite size with increase  $T_a$ . An asymmetrical shape of the Raman spectral line just over the threshold also indicated the evidence came from the nm-size crystals [2]. This same asymmetric spectral shape was reported concern about the nano crystalline Si, diamond, Ge, etc. A transmission electron microscope (TEM) can observe the nm-size image and evaluate the crystal phase from the electron diffraction measurements.

The coating layers for different  $T_a$  were scratched in ethanol and their grains were observed by TEM. Typical TEM images of the scratched grains and their electron diffraction patterns for  $T_a = 400$  and  $550$  °C were shown in Fig. 1 and Fig. 2, respectively. The diameter of the electron transmission was set at  $0.8$   $\mu\text{m}$ . These patterns showed that the coating layer shown in Fig. 1 is single-crystal with larger crystallite size, on the other hand, the coating layer shown in Fig. 2 became a polycrystal with smaller crystalline size. These differences might be caused by the growth rate of the crystal layer at different  $T_a$ . The disagreement on the crystallite size estimation between Raman spectroscopy and TEM analysis is under consideration.

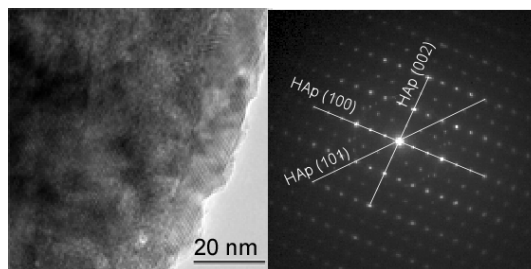


Figure 1 HR-TEM image of coating layer and electron diffraction pattern for  $T_a = 400$  °C.

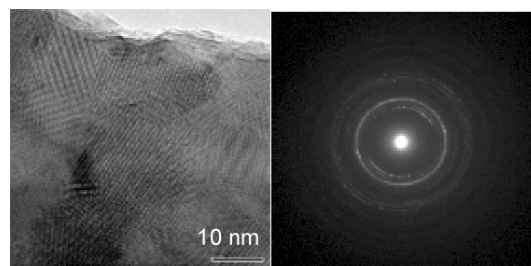


Figure 2 HR-TEM image of coating layer and electron diffraction pattern for  $T_a = 550$  °C.

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**References:** [1] H. Yashiro, and M. Kakehata, Appl. Phys. Lett. **120**, 131602 (2022).  
[2] I.H. Campbell and P.M. Fauchet, Solid State Comm. **58**, 10 739-741 (1986).